26	arcn	Notes	

_	Application No.	Applicant(s)	
	10/706,090	SUGAMOTO ET AL.	
	Examiner	Art Unit	
	Granvill D Lee, Jr	2825	

SEARCHED			
Class	Subclass	Date	Examiner
438	745,689	9/1/2004	GL
438	693,704	9/1/2004	GL
438	494,498	9/1/2004	GL
438	504	9/1/2004	GL
438	734-735	9/1/2004	GL
216	56,62	9/1/2004	GL
216	103-109	9/1/2004	GL
156	345.1	9/1/2004	GL
156	345.11	9/1/2004	GL
156	912-915	9/1/2004	GL
ABose	Winter	3/14/2005	GL
ABwe	UBDATED	9/15/2005	G2

INTERFERENCE SEARCHED			
Class	Subclass	Date	Examiner
	1		

SEARCH NOTES (INCLUDING SEARCH STRATEGY)		
	DATE	EXMR
second solution, oxidative acid, oxidizing agent crystal defects, secco etch, cleaning, selective etching, HF,defect-free	9/1/2004	GL
UPDATEV See EAST	3/16/2005 L 9/15/3008	9
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